



US00D737785S

(12) **United States Design Patent**
Yoshida et al.

(10) **Patent No.:** **US D737,785 S**
(45) **Date of Patent:** **** Sep. 1, 2015**

(54) **BOAT FOR SUBSTRATE PROCESSING APPARATUS**

(71) Applicant: **Hitachi Kokusai Electric Inc.**, Tokyo (JP)

(72) Inventors: **Hidenari Yoshida**, Toyama (JP);
Tomoshi Taniyama, Toyama (JP)

(73) Assignee: **HITACHI KOKUSAI ELECTRIC INC.**, Tokyo (JP)

(**) Term: **14 Years**

(21) Appl. No.: **29/480,457**

(22) Filed: **Jan. 27, 2014**

(30) **Foreign Application Priority Data**

Jul. 29, 2013 (JP) 2013-017235

(51) **LOC (10) Cl.** **13-03**

(52) **U.S. Cl.**
USPC **D13/182**

(58) **Field of Classification Search**
USPC D13/182; D15/144, 144.1, 199;
118/715, 500, 728, 729; 211/41.18;
432/253, 258; 156/345.51, 345.52,
156/345.53, 345.55; 414/217, 220.01,
414/935-941
CPC C23C 16/458; C23C 16/4581; C23C
16/4582; C23C 16/4583; C23C 16/4584;
C23C 16/4586; C23C 16/4587; C23C
16/4588; C30B 31/14; H01L 21/673; H01L
21/67303; H01L 21/67306; H01L 21/67309;
H01L 21/67313; H01L 21/67316; H01L
21/67323; H01L 21/67326; H01L 21/6733
See application file for complete search history.

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Primary Examiner — Elizabeth J Oswecki

(74) *Attorney, Agent, or Firm* — Fitch, Even, Tabin and Flannery LLP

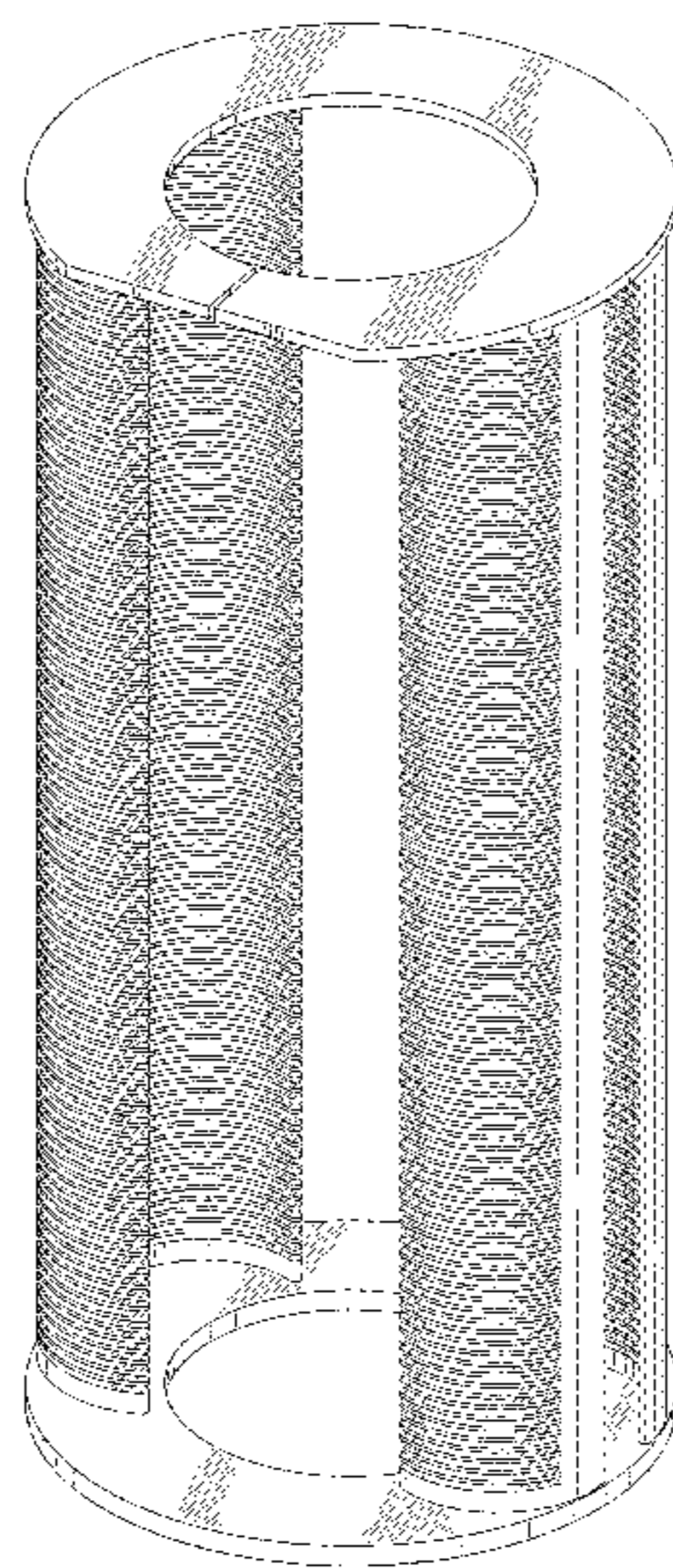
(57) **CLAIM**

The ornamental design for a boat for substrate processing apparatus, as shown and described.

DESCRIPTION

FIG. 1 is a front, top and right side perspective view of a boat for substrate processing apparatus showing our new design; FIG. 2 is a front elevational view thereof; FIG. 3 is a rear elevational view thereof; FIG. 4 is a left side elevational view thereof; FIG. 5 is a right side elevational view thereof; FIG. 6 is a top plan view thereof; FIG. 7 is a bottom plan view thereof; FIG. 8 is a cross sectional view taken along line 8-8 in FIG. 2; and, FIG. 9 is a cross sectional view taken along line 9-9 in FIG. 2.

1 Claim, 8 Drawing Sheets



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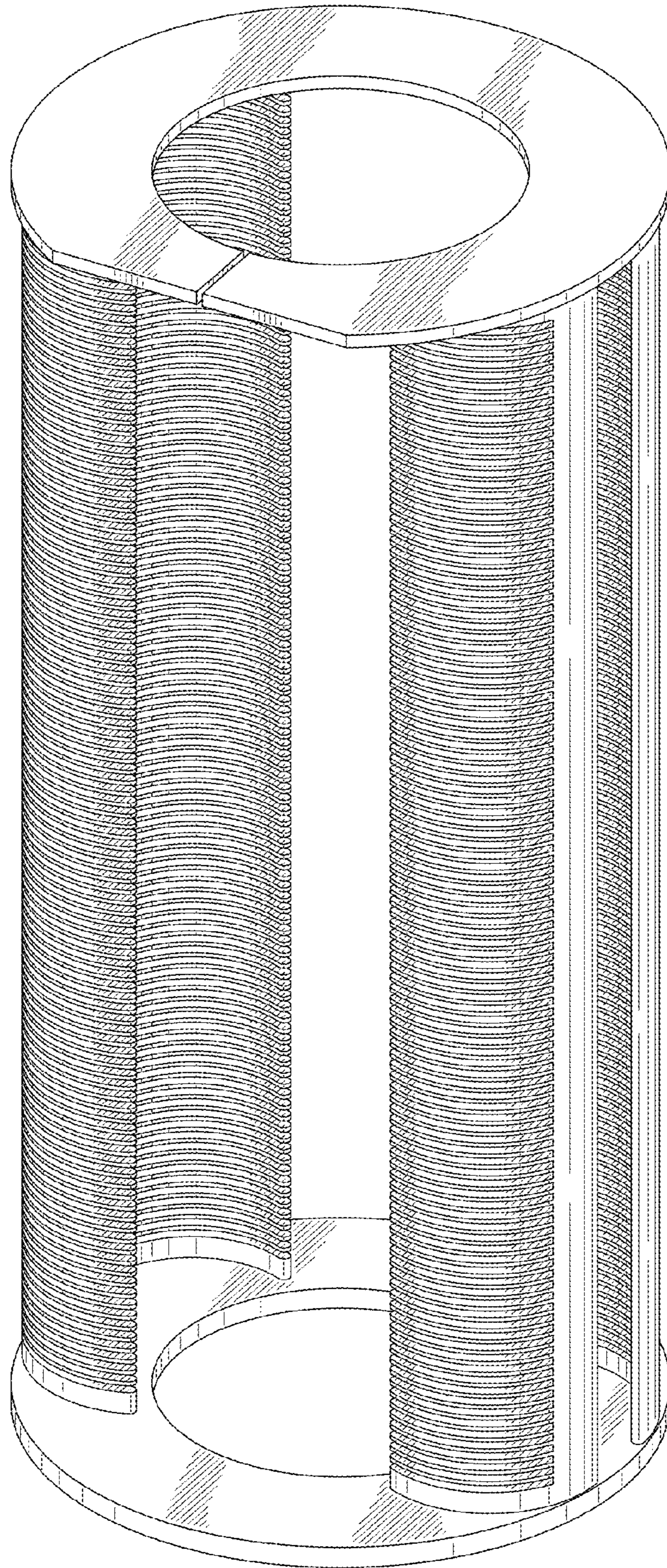
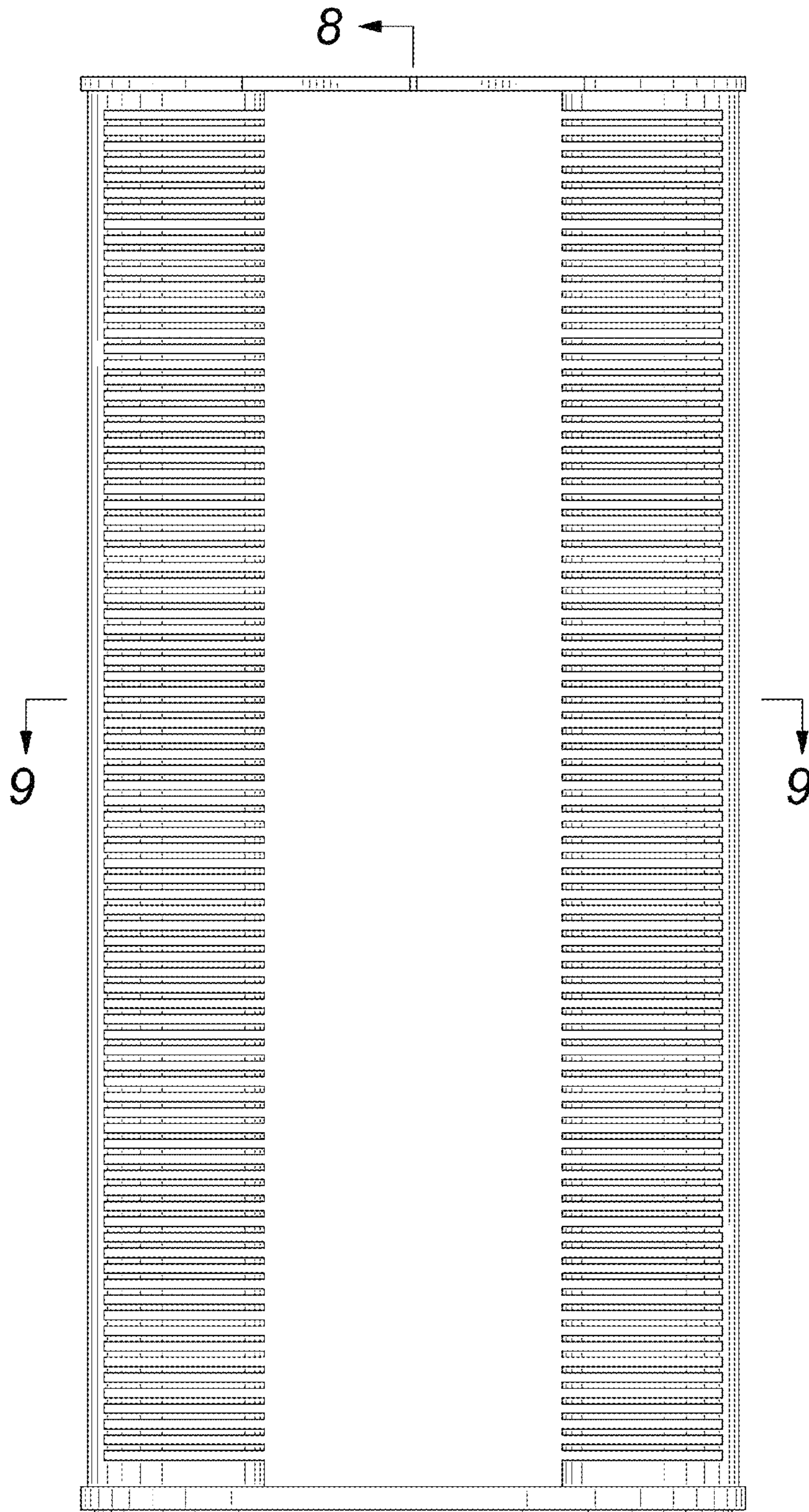


FIG. 1



8 ←
FIG. 2

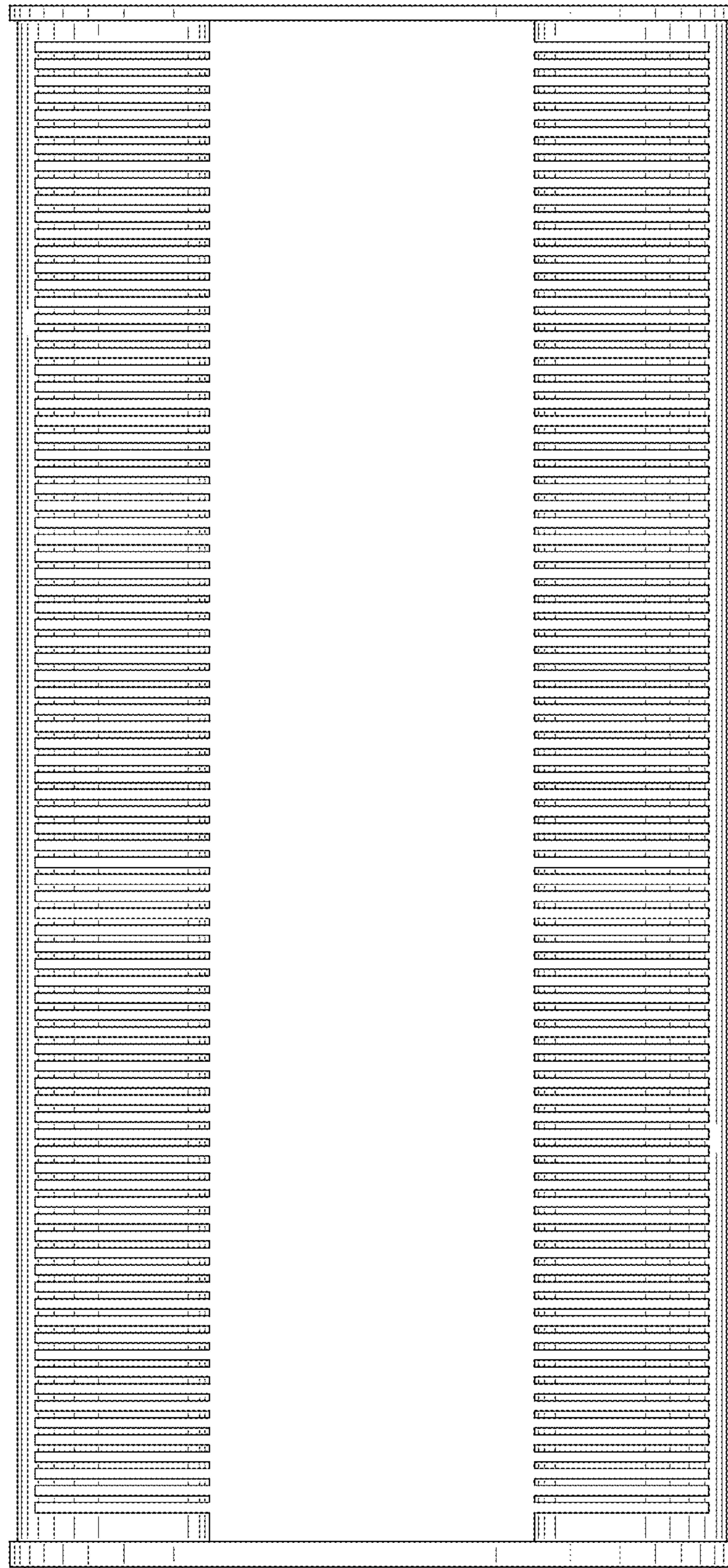


FIG. 3

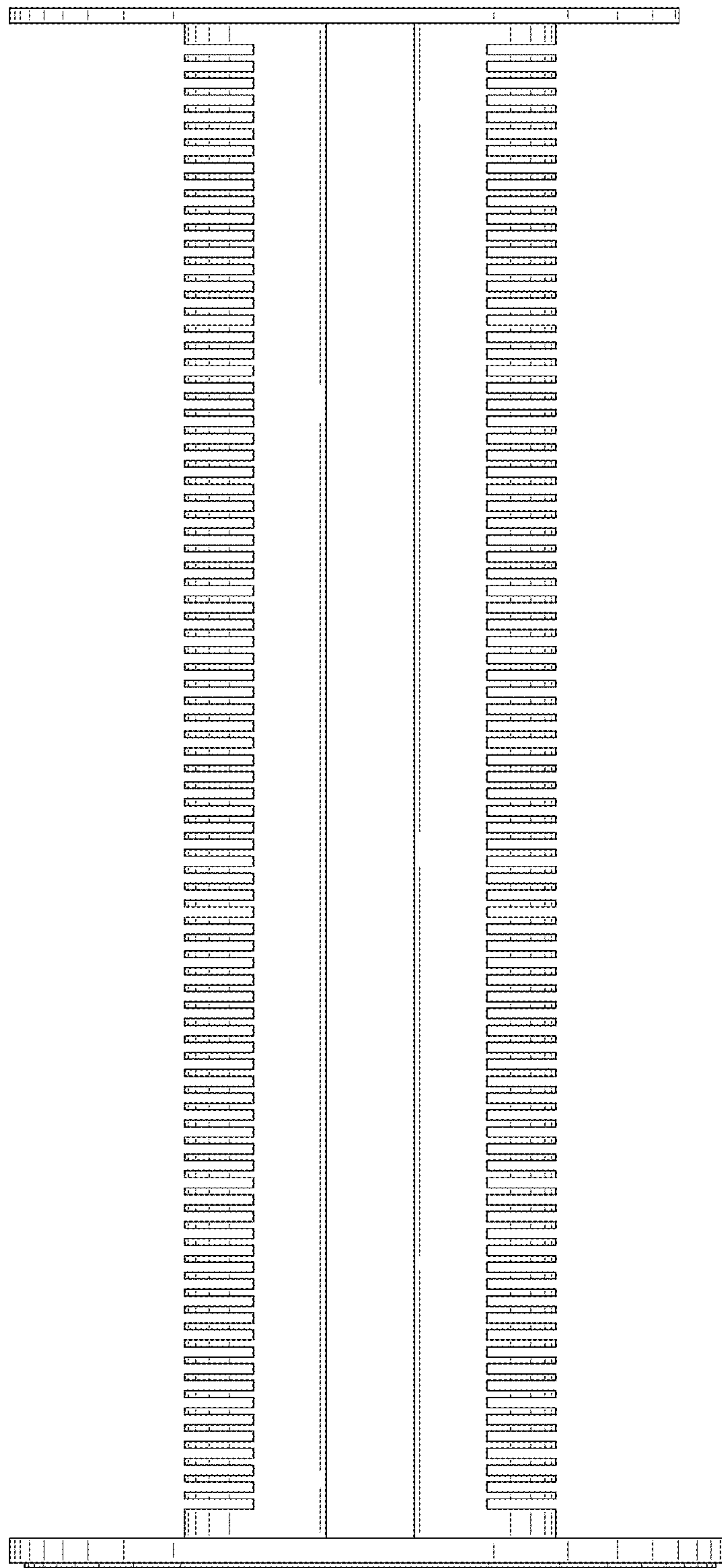


FIG. 4

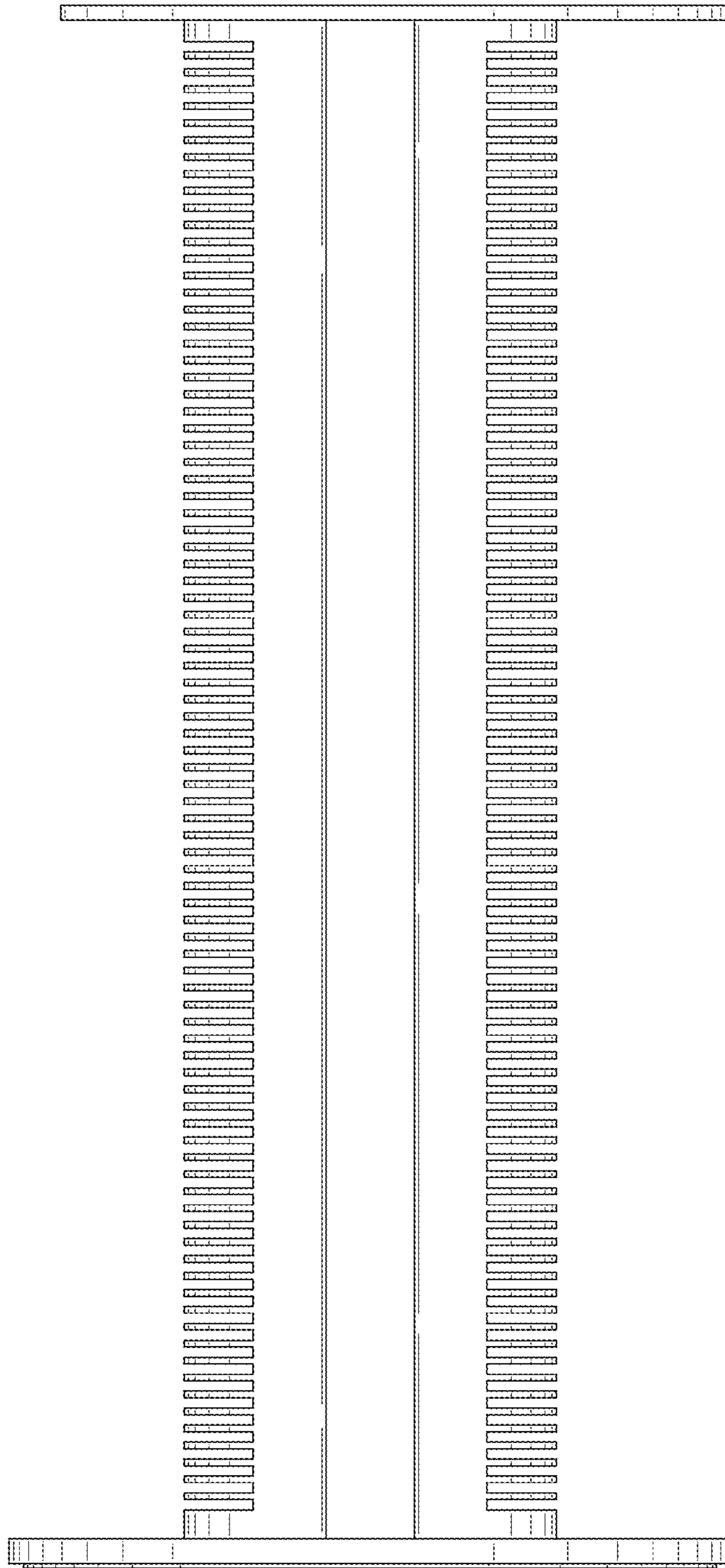


FIG. 5

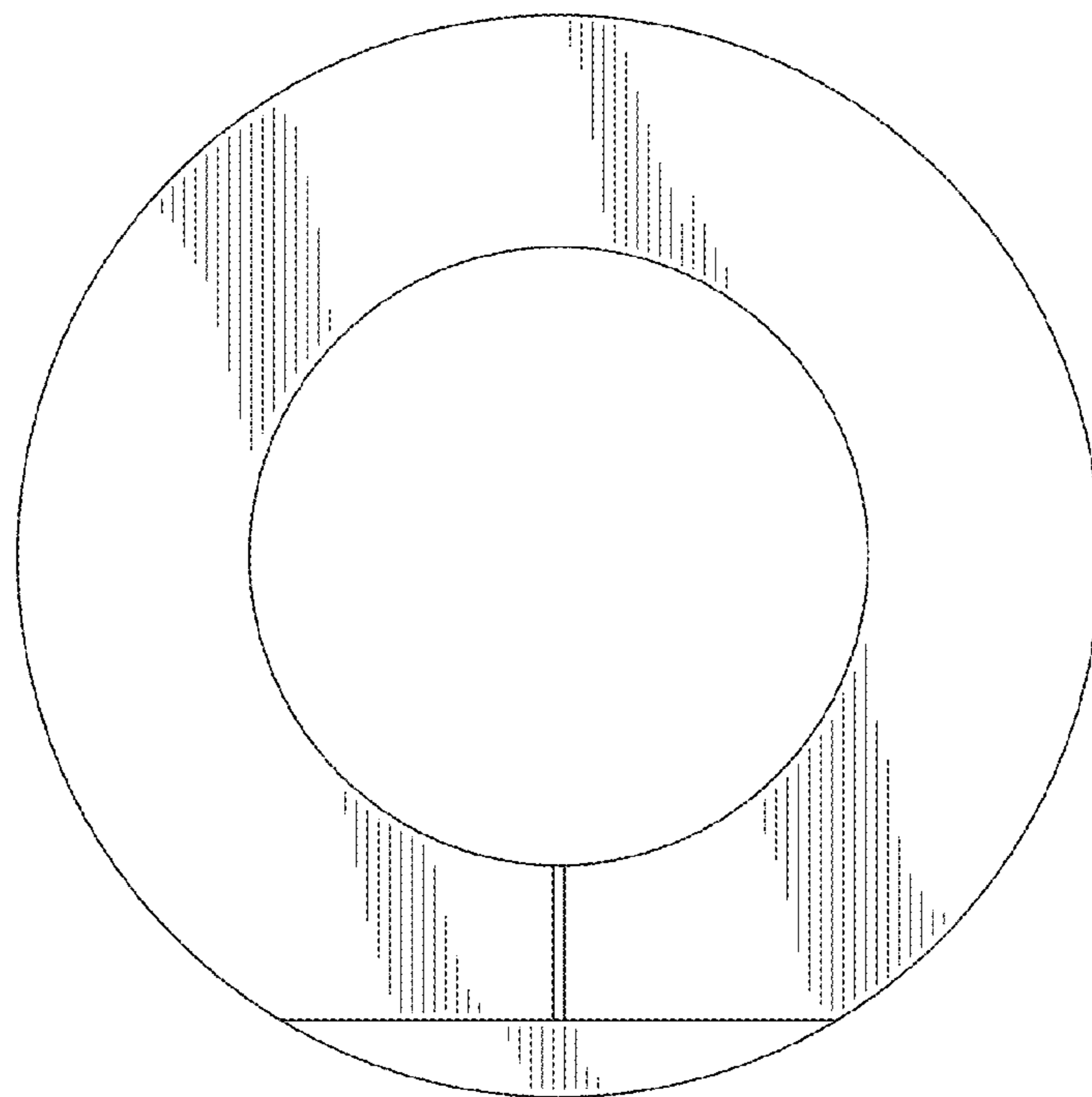


FIG. 6

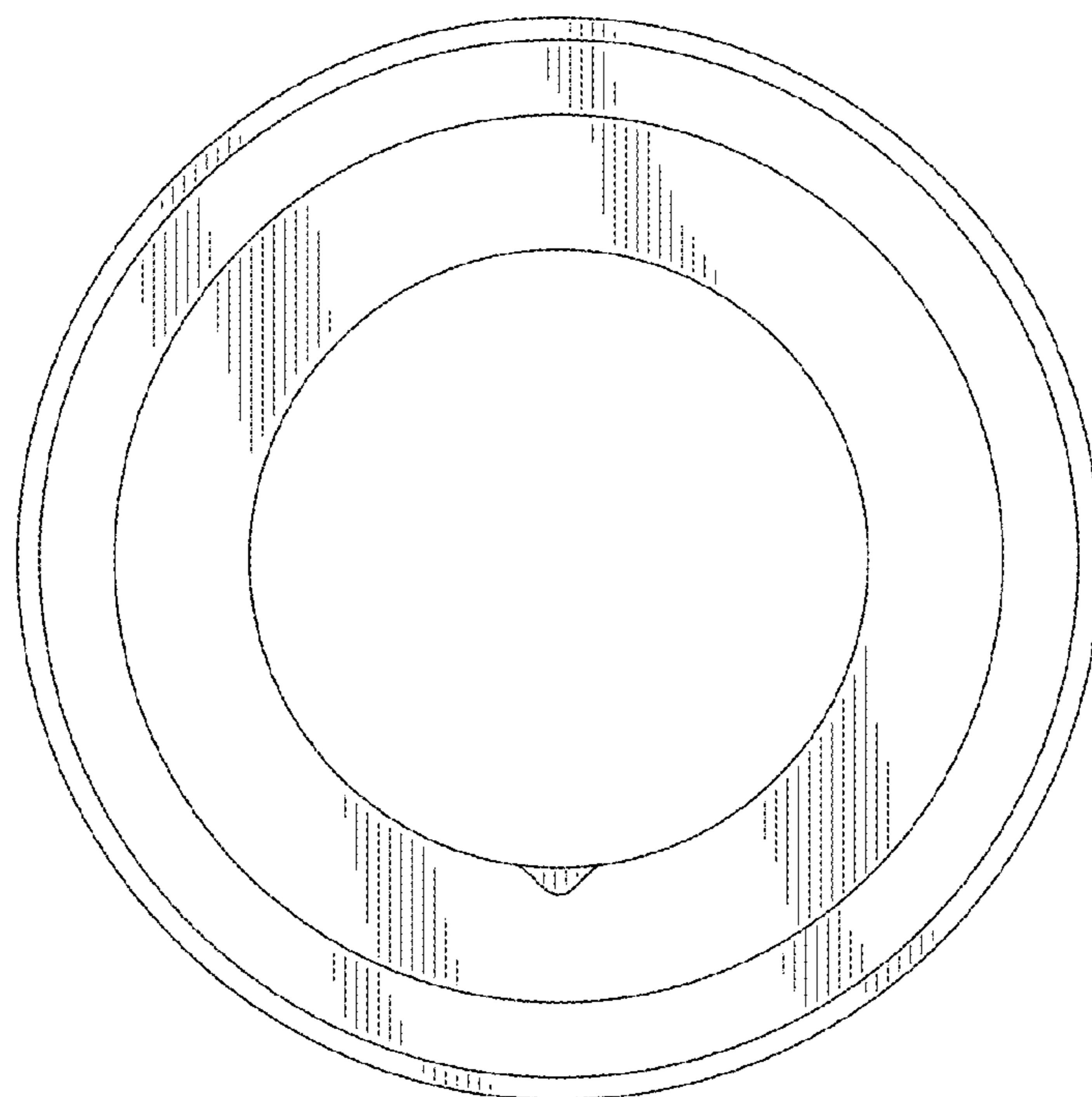


FIG. 7

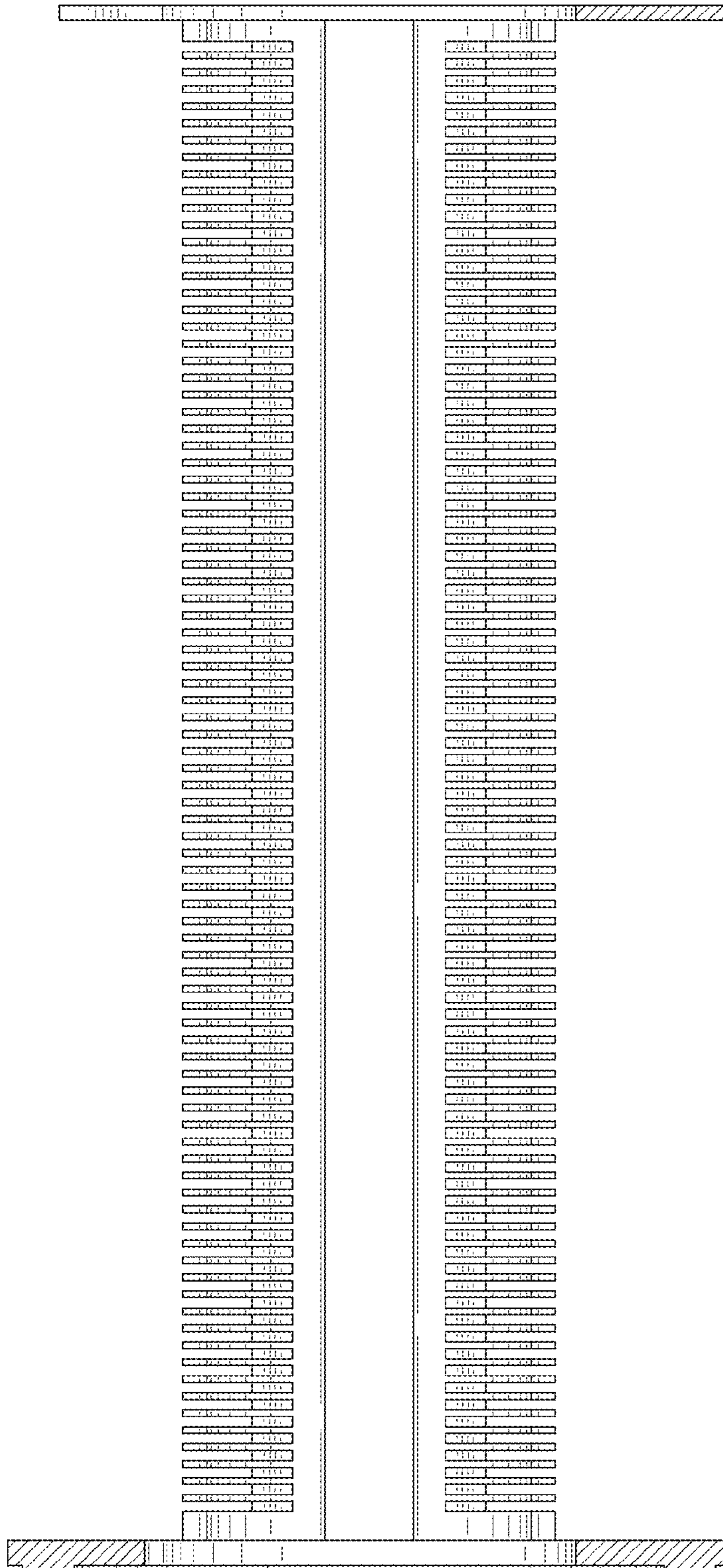


FIG. 8

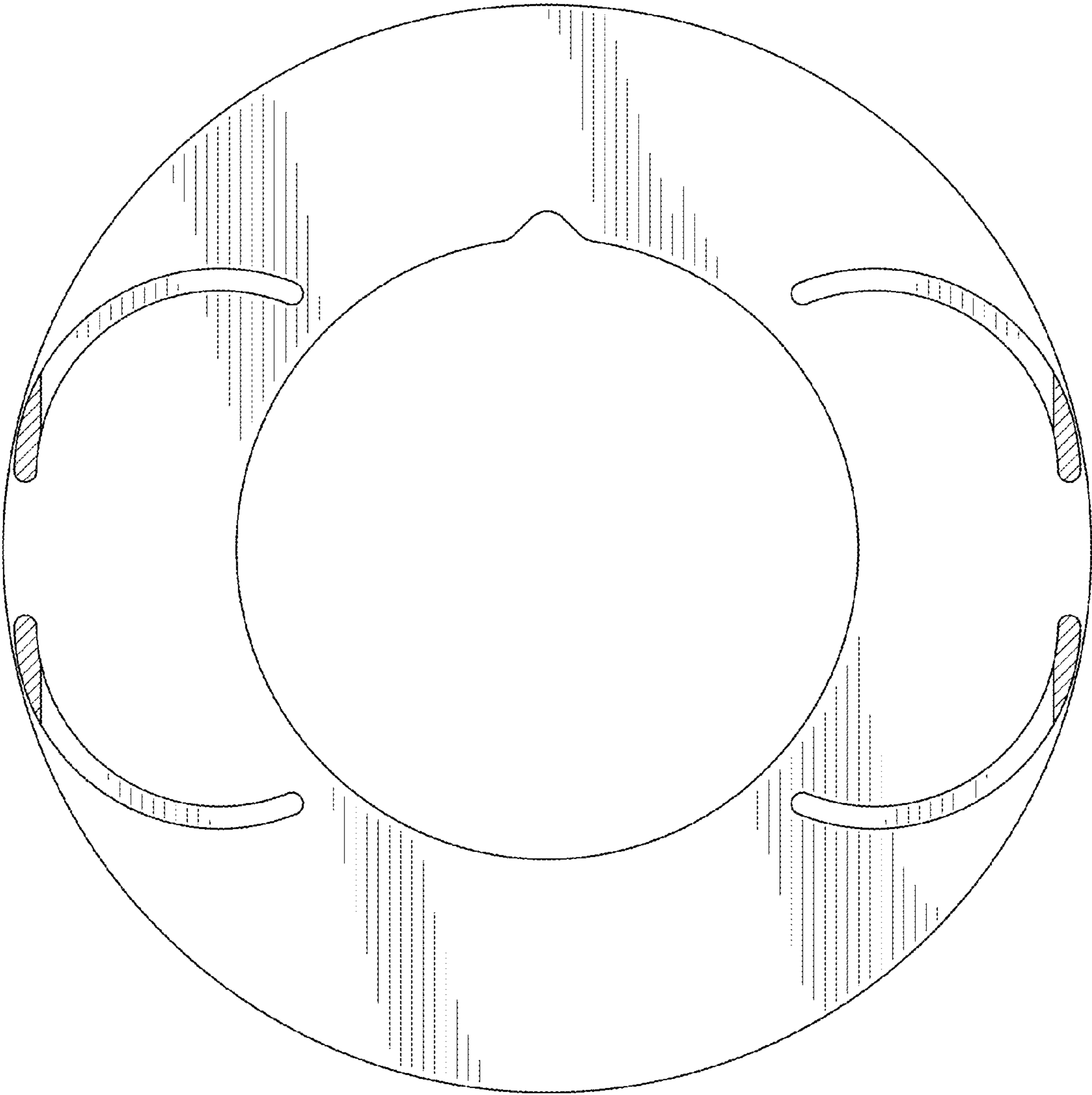


FIG. 9